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TT		ENOKI ET AL.; "Design and Characteristics of InGaAs/InP Composite-Channel HEFT's;" IEEE Transactions on Electron Devices, Vol. 42, No. 8, August 1995; 0018-9383/95; pages 413-418.	
11		HOKE ET AL.; "Molecular Beam Epitaxial Growth and Device Performance of Metamorphic High Electron Mobility Transistor Structures Fabriated on GaAs Substrates;" J. Vac. Sci. Technol. B 17(3), May/June 1999; American Vacuum Society; 0734-211X/99/71(3)/1131/5; pages 1131-1135.	
11		WHELAN ET AL.; "GaAs Metamorphic HEMT (MHEMT): An Attractive Alternative to InP HEMTs for High Performance Low Noise and Power Applications;" 2000 IEEE 0-7803-6320-5-00; pages 337-340.	
7r		detALAMO ET AL; "Breakdown in Millimeter-Wave Power InP HEMT's: A Comparison with GaAs PHEMT's;" IEEE Journal of Solid-State Circuits, Vol. 34, No. 9, September 1999; 0018-9200/99; pages 1204-21.	
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